

Applicant(s): Philippe STAIB

Serial No: 10/664,718 Group Art Unit: 2881

Filed: September 17, 2003 Examiner:

Att. Docket No.: B1180/20019 Confirmation No.: 4374

For: ELECTRON DIFFRACTION SYSTEM FOR USE IN PRODUCTION

ENVIRONMENT AND FOR HIGH PRESSURE DEPOSITION TECHNIQUES (AS

AMENDED)

## PRELIMINARY AMENDMENT

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Sir:

## INTRODUCTORY COMMENTS

Prior to initial examination on the merits, please amend the above-identified application as follows:

Amendments to the Specification begin on page 2 of this paper.

Remarks/Arguments begin on page 3 of this paper.